

X-Ray Optics in Stockholm

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Anders Holmberg, and Ulrich Vogt
&
Hans Hertz

Applied Physics/KTH
Stockholm

Today

Soft x-rays :

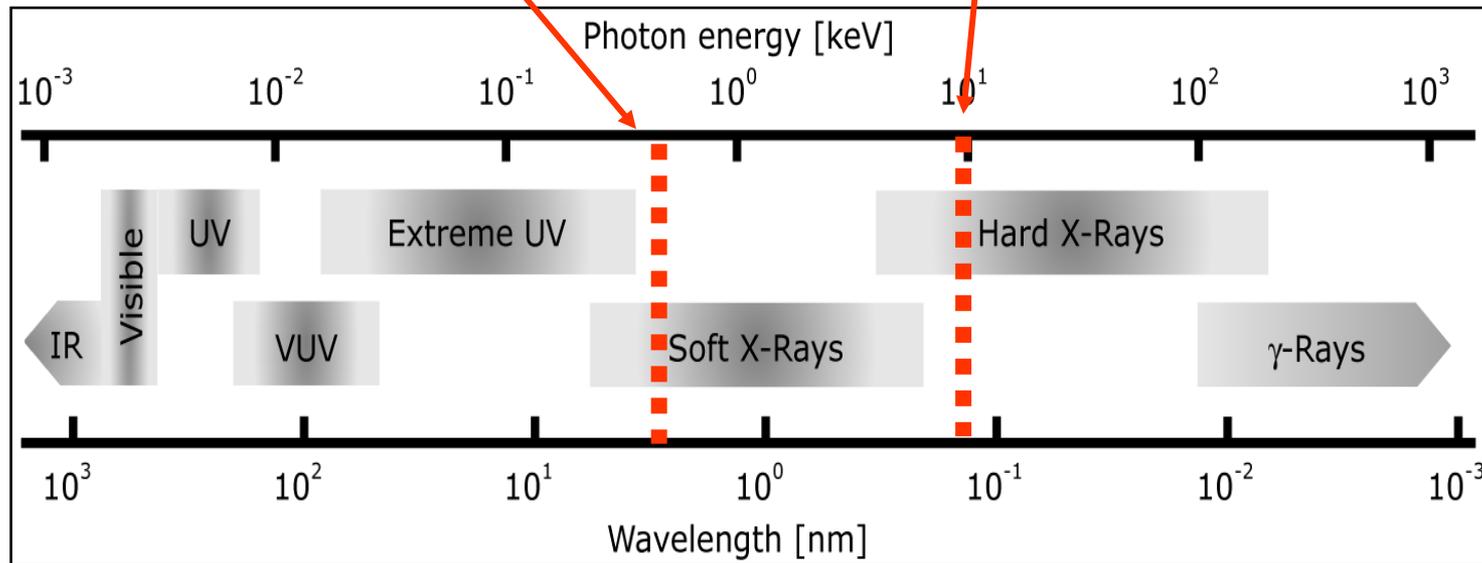
Diffractive x-ray optics

for laboratory x-ray microscopy

Hard x-rays :

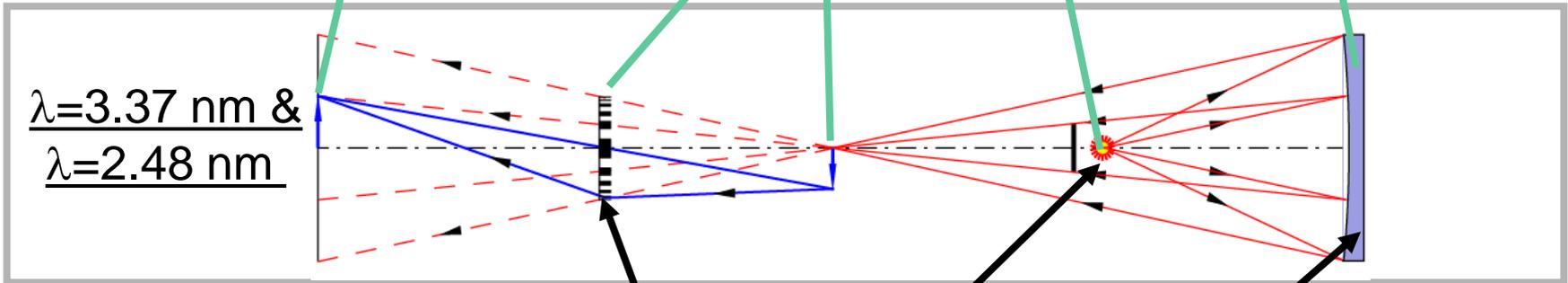
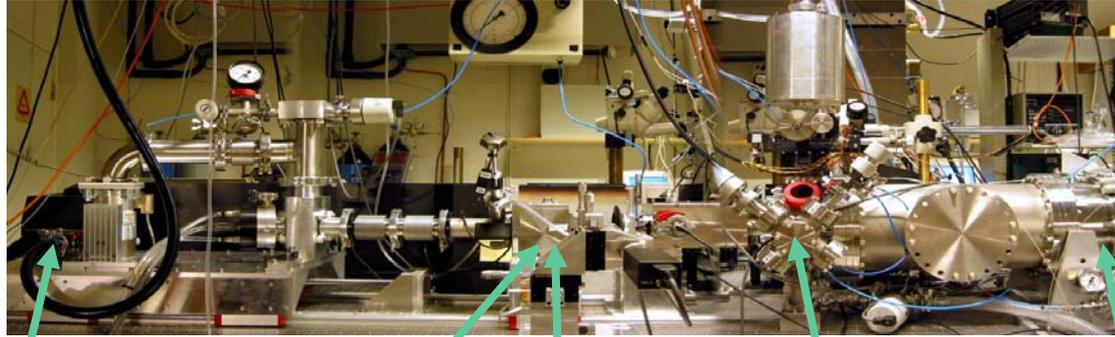
Diffractive x-ray optics

for MAX IV, XFEL, LCLS



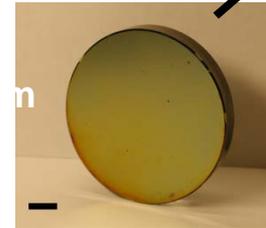
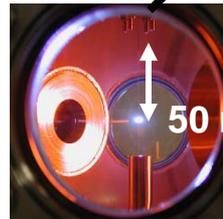
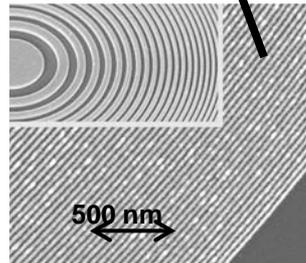
Soft x-rays:

Laboratory water-window x-ray microscopy



$\lambda = 3.37 \text{ nm}$ &
 $\lambda = 2.48 \text{ nm}$

Micro zone plates for high-resolution imaging

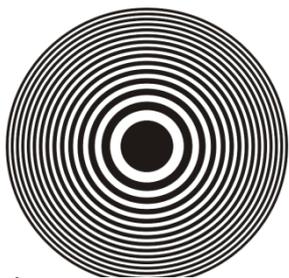


Normal-incidence multilayer mirrors as condensers

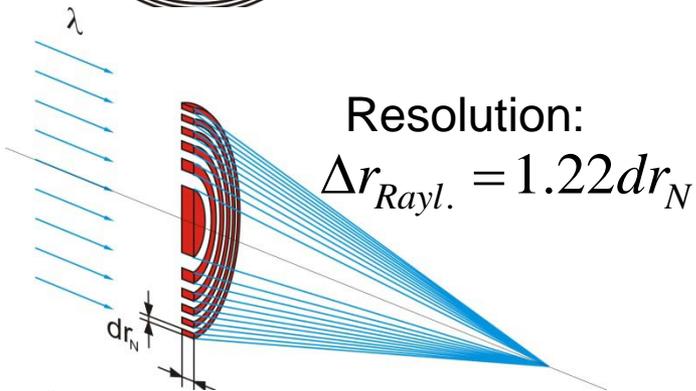
Berglund et al, J. Microsc. (2000), Johansson et al, RSI (2002) Takman et al, J. Microsc. (2007)

Soft x-ray optics: Zone plates

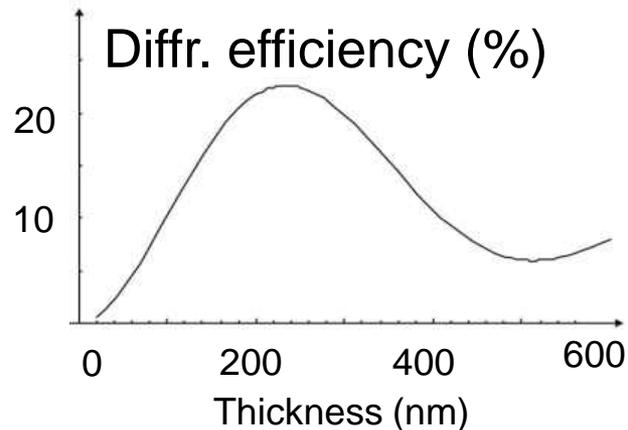
Basics



Circular
diffraction
gratings

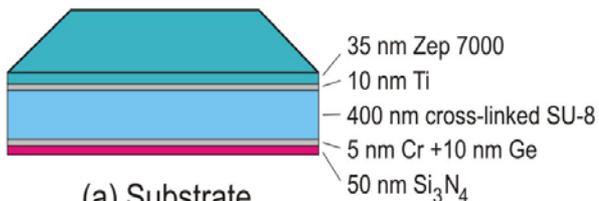


Diffr. efficiency (%)

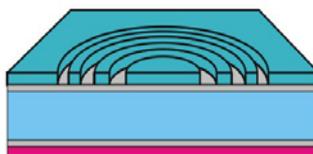


Nano-fab process for Ni zone plates

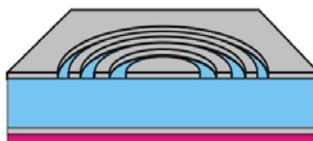
@ Albanova Nanofab Lab



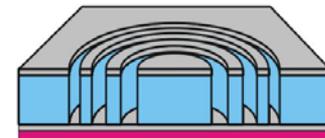
(a) Substrate
Preparation



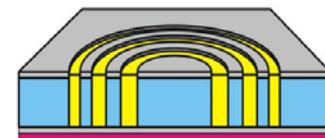
(b) Exposure and
Development



(c) RIE with BCl₃



(d) RIE with O₂



(e) Nickel Plating

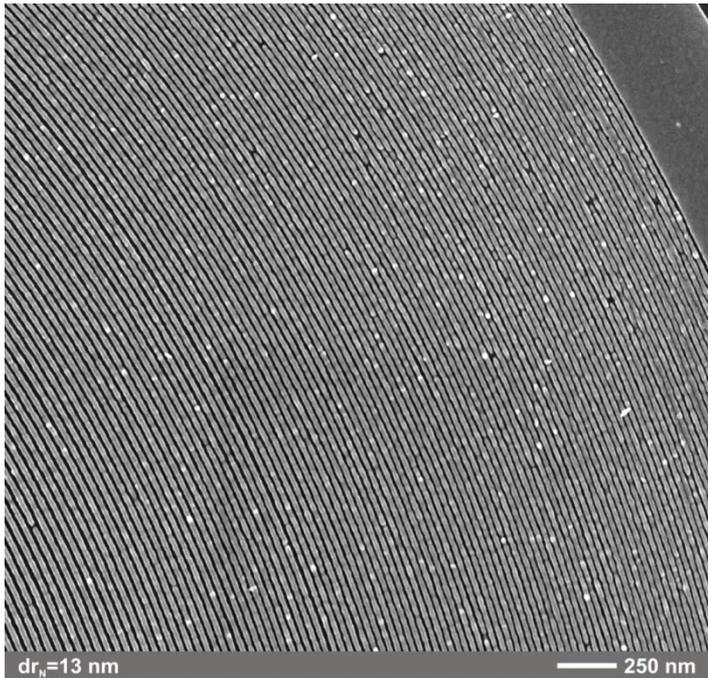


(f) Stripping, RIE
with BCl₃ / O₂

Holmberg et al, MNE (2003),

$dr_N=13$ nm Ni zone plates

Single-write Ni ZP



$\varnothing=19 \mu\text{m}$

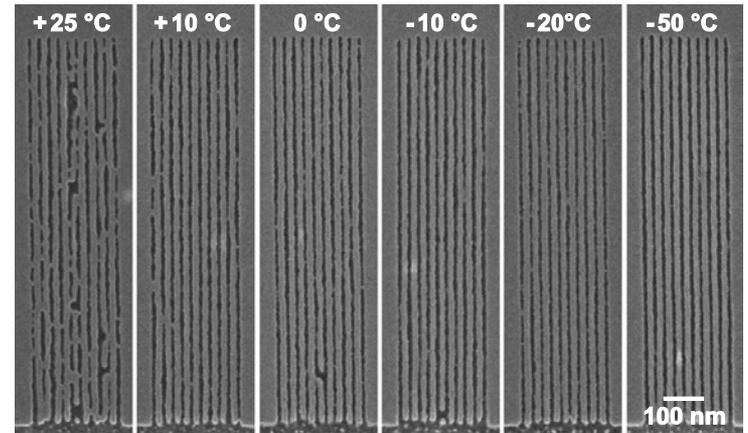
$dr_N=13$ nm; $h=35$ nm

$f=100 \mu\text{m}$ @ $\lambda=2.48$ nm

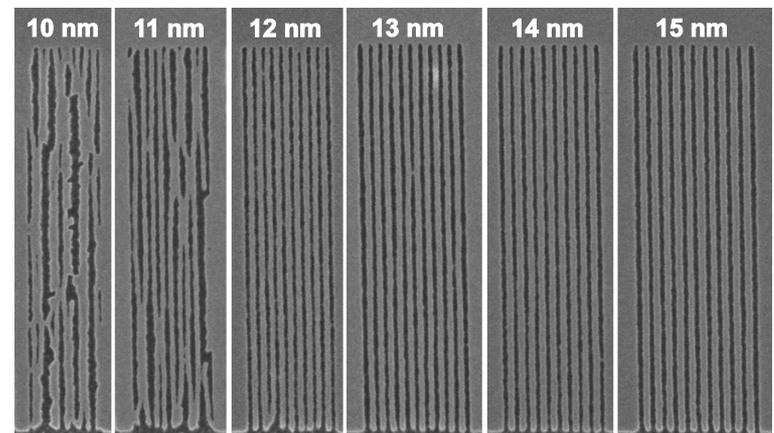
Excellent uniformity

Efficiency: 2.7% (15 nm/ $h=55$ nm zp)

Cold development: ZEP in hex acet



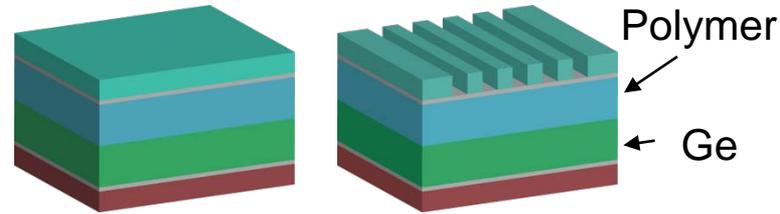
Mold stability



Reinspach et al, JVST B (2009)

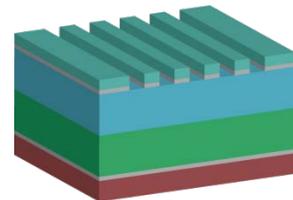
Ni-Ge efficiency enhancement

Our standard nickel process
PLUS one extra step

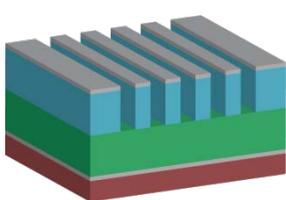


1. Substr. prep.

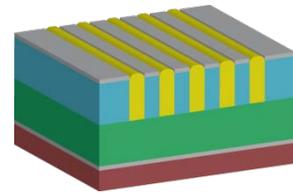
2. E-beam litho.



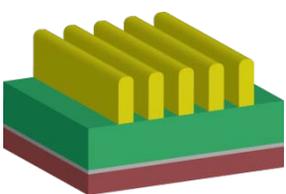
3. Ti etch



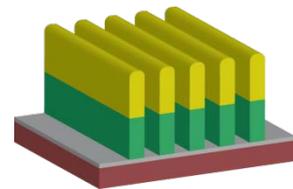
4. Polymer etch



5. Ni plating

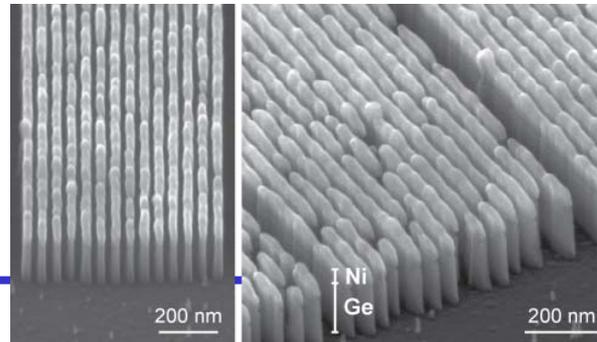
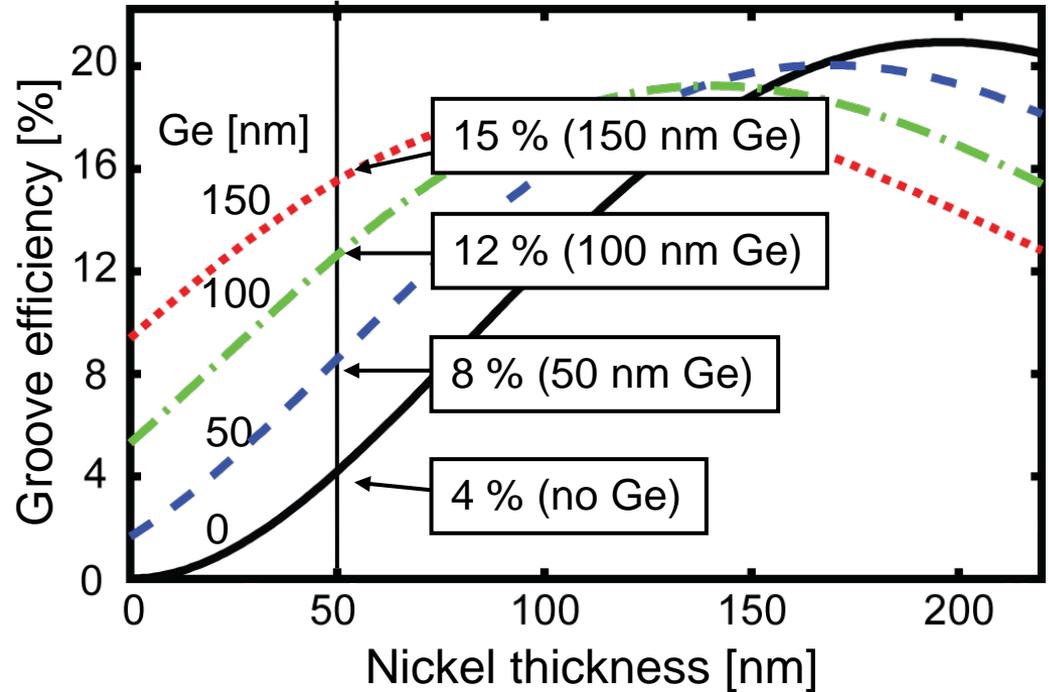


6. Mold strip



7. Ge etch, CHF_3

Multiply the efficiency of narrow-line
Ni zone plates



30 nm zp made

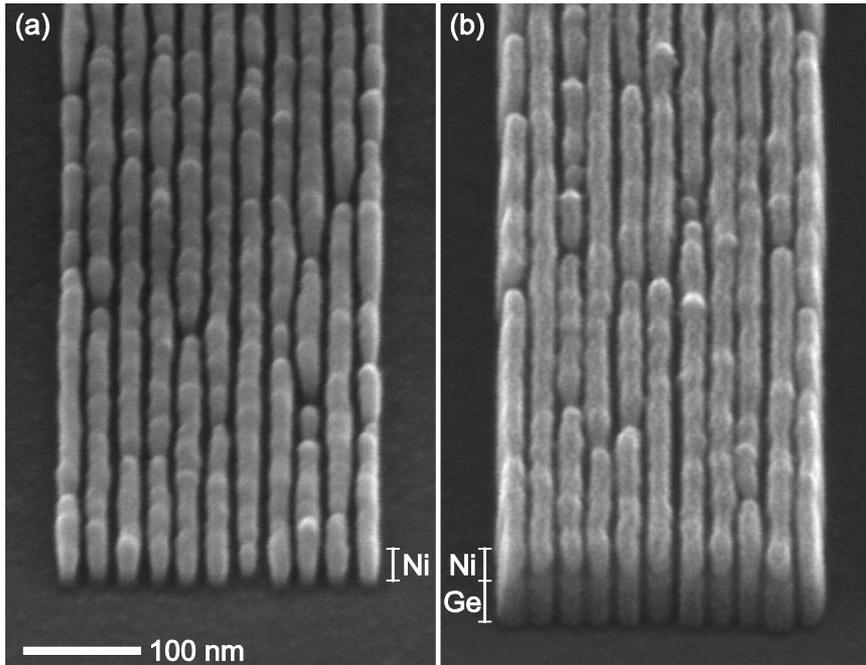
Lindblom et al, JVST (2009)

Recent results:

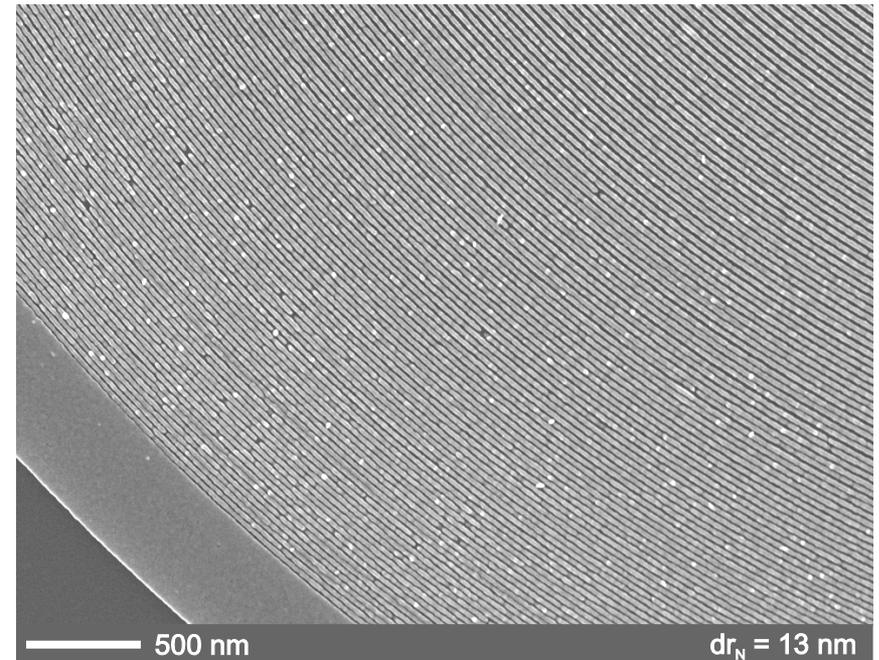
13 nm Ni-Ge zone plates

13 nm Ni-Ge gratings

w/ 35 nm Ni and 45 nm Ge



13 nm Ni-Ge zone plate



Diam: 19 μm

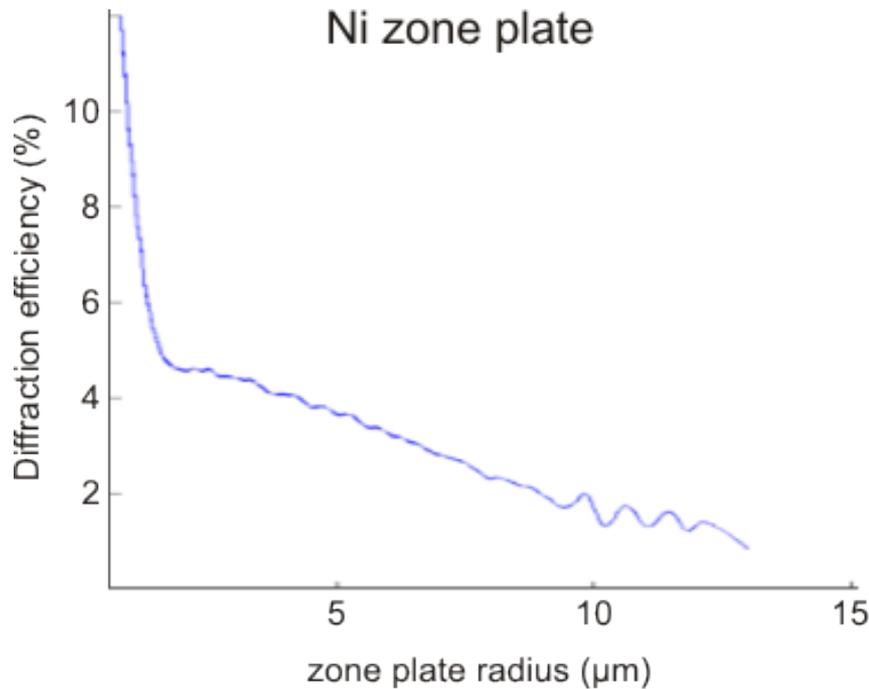
Focal length: 100 μm (@2.48 nm)

dr_N : 13 nm:

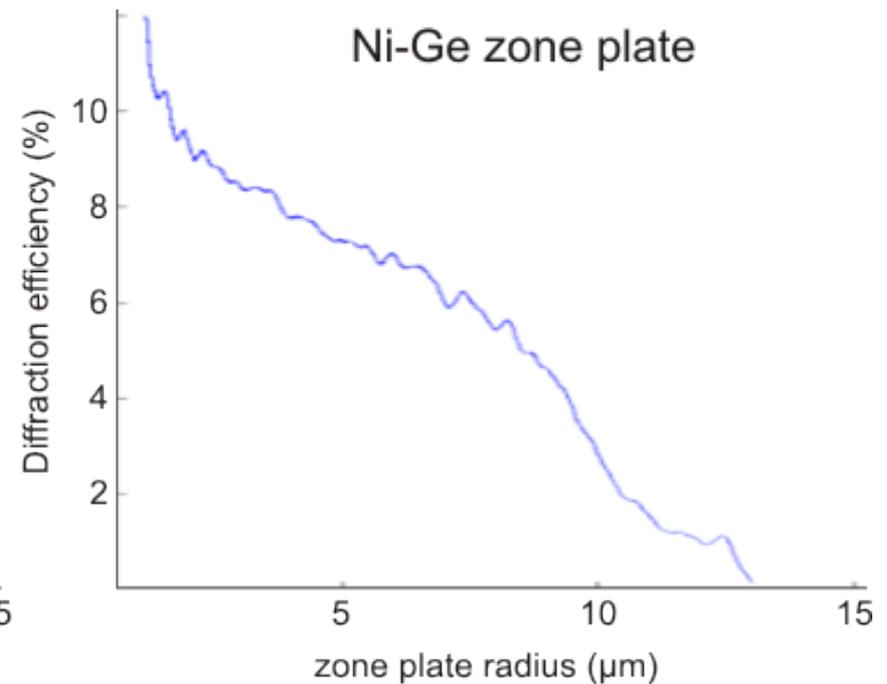
Thickness: 35 nm Ni + 45 nm Ge

Reinspach et al, JVST (2011)

15 nm Ni-Ge zone plate efficiency



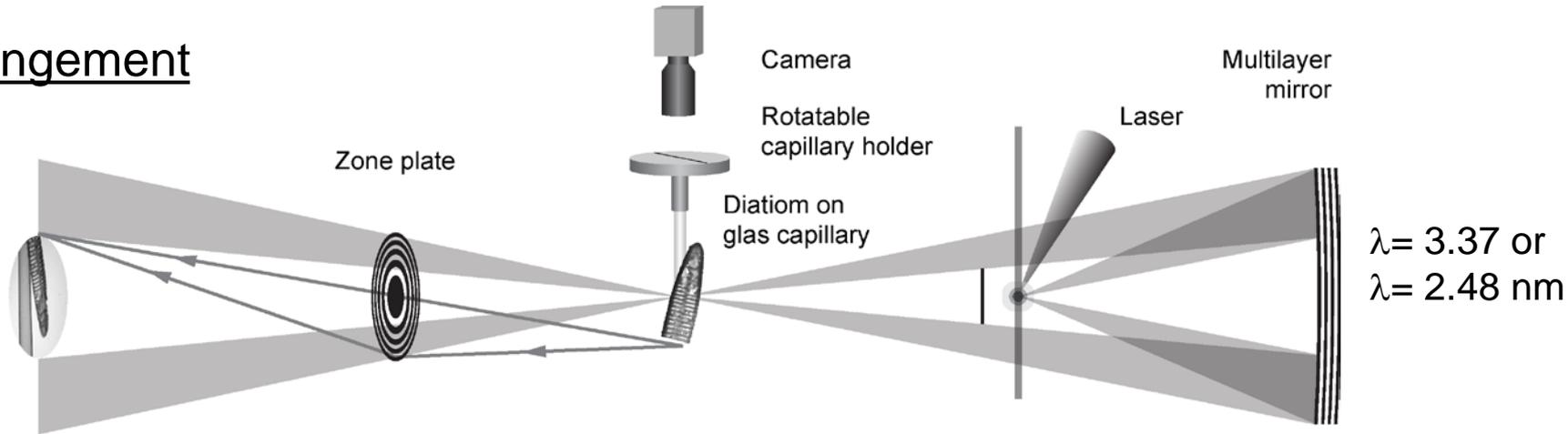
Average: 2.4%



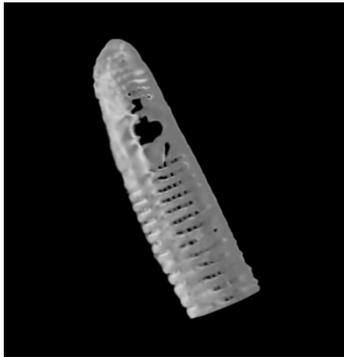
Average: 4.3%

Cryo micro-tomography w/ lab. water-window XRM

Arrangement



Diatom reconstruction



$\lambda = 3.37$ nm

Filtered. back. proj.

53 projections

140 nm resol.

Bertilsson et al, Opt Expr (2009)

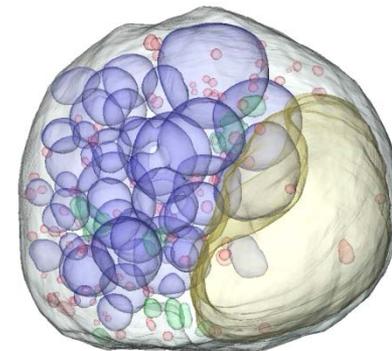
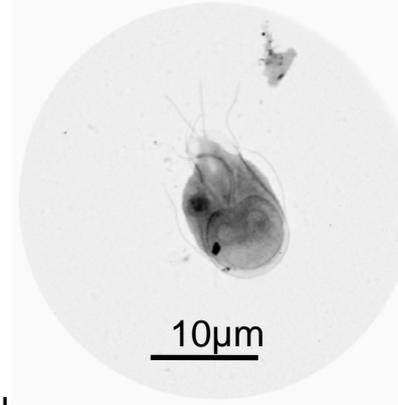
First lab cryo tomo: parasites and human kidney cell



$\lambda = 2.48$ nm

Filtered. back. proj.

200 projections

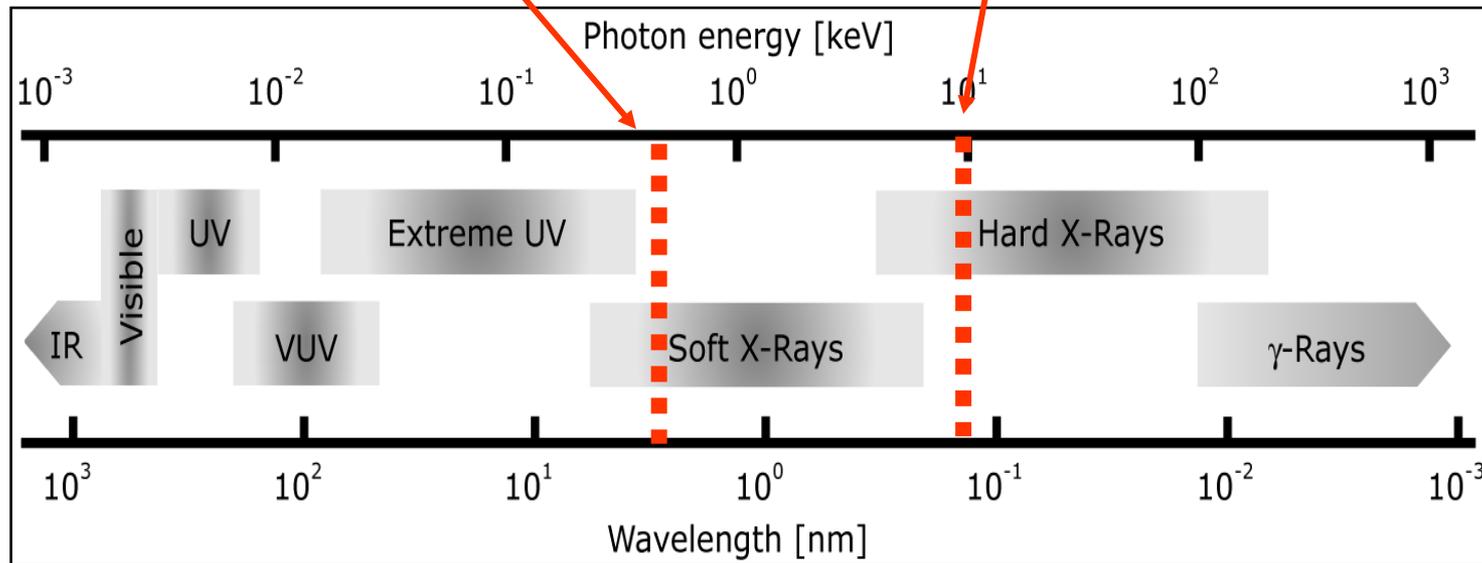


Bertilsson et al, Opt Lett (2011); Hertz et al J. Struct Biol (2012)

Today

Soft x-rays :
Diffractive X-ray optics
for Laboratory X-Ray Microscopy

Hard x-rays :
Diffractive X-Ray Optics
for MAX IV, XFEL, LCLS



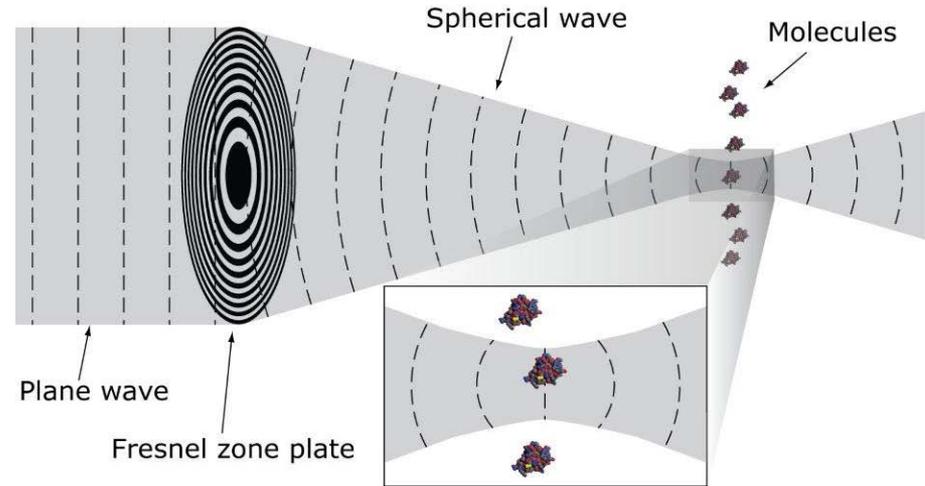
Hard X-Ray Diffractive Optics

(PI: Ulrich Vogt; Nanolab: Anders Holmberg)

XFEL @ Hamburg

- New materials for substrate and optic
- Cooling of high heat load
- Large diameter (>1 mm)
- Diffraction-limited (low aberrations)
- Metrology for efficiency and wave front
- "Mass production" of single-shot optics?

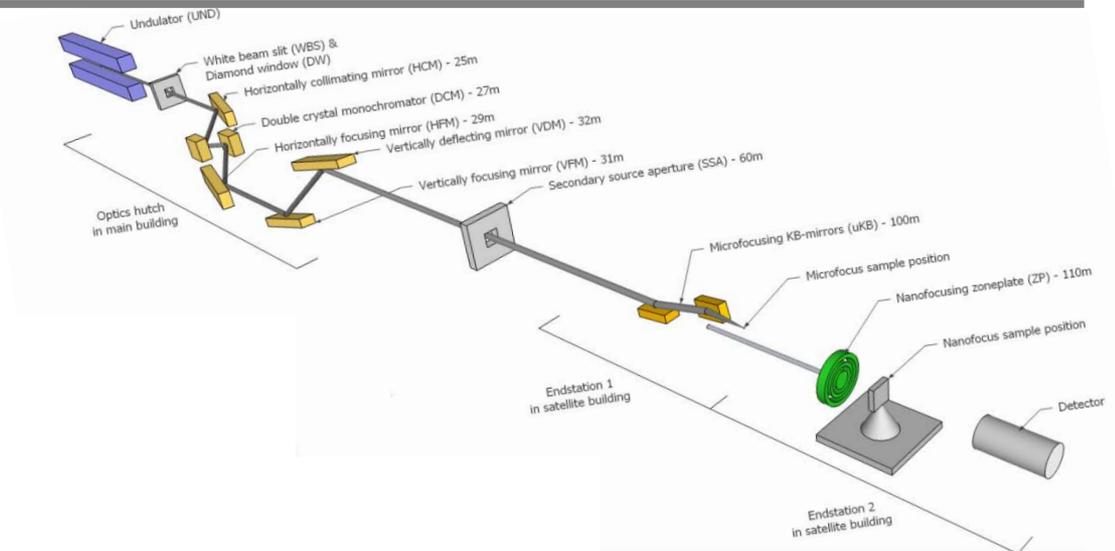
LCLS



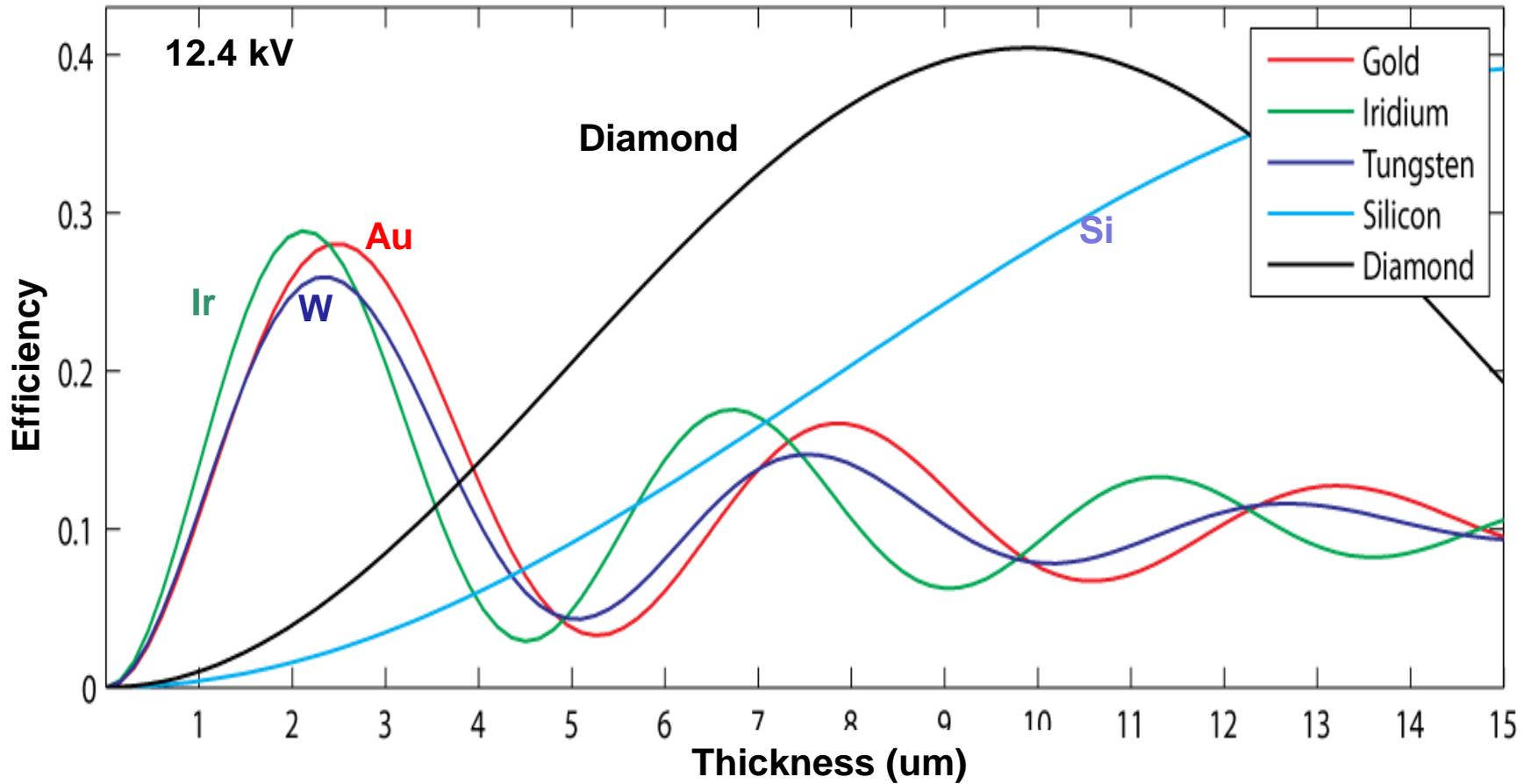
High-brilliance sources

- MAX IV – NanoMAX BL

Lab sources

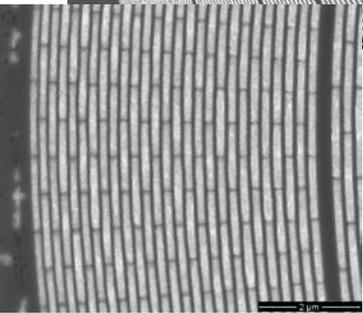
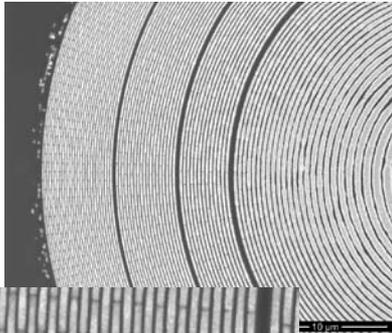


Materials



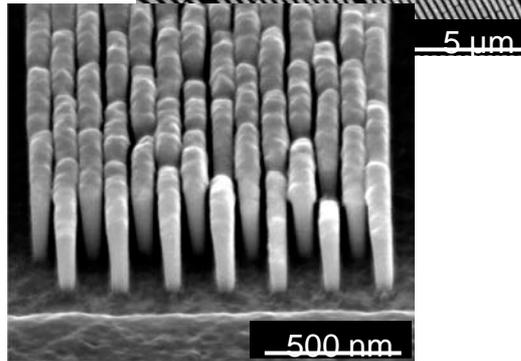
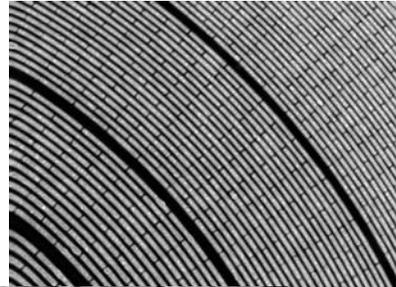
Hard X-Ray Metal Zone Plates: Fabrication

Gold Electroplated



100 nm half-period,
670 nm high,
8% eff @ 8 keV

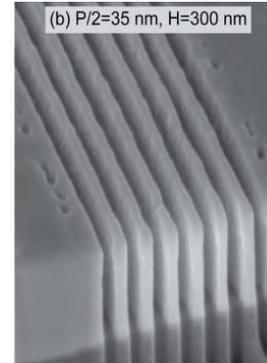
Platinum Electroplated



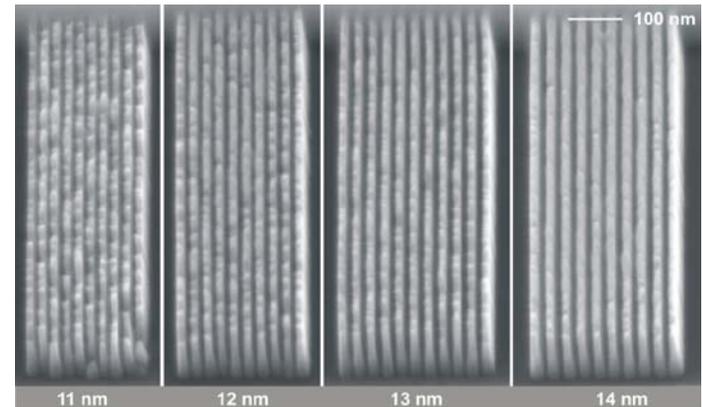
50 nm half-period,
400 nm high,
5.5-6.5 % eff @ 8 keV

Chubarova et al, Microel. Engin (2011).

Tungsten SF₆ /O₂ dry etch



Half pitch: 35 nm
Height: 300 nm
Aspect ratio: 8.5



Half pitch: 11-14 nm
Height: 90 nm
Aspect ratio: 6-8

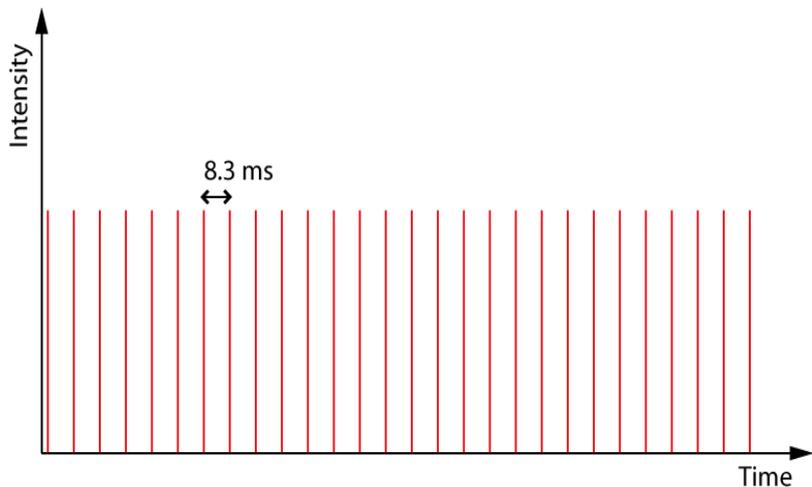
Reinspach et al, JVST B (2011)

Free-electron lasers: Source properties

	LCLS	European XFEL (SASE1)
Photon energy [Wavelength]	8 keV [0.15 nm]	12.4 keV [0.1 nm]
Pulse energy	2 mJ	2 mJ
Repetition rate	120 Hz	Trains of 2700 pulses in 0.6 ms
Beam size at lens position	750 μm (FWHM)	982 μm (FWHM)
E/ Δ E	500	1000

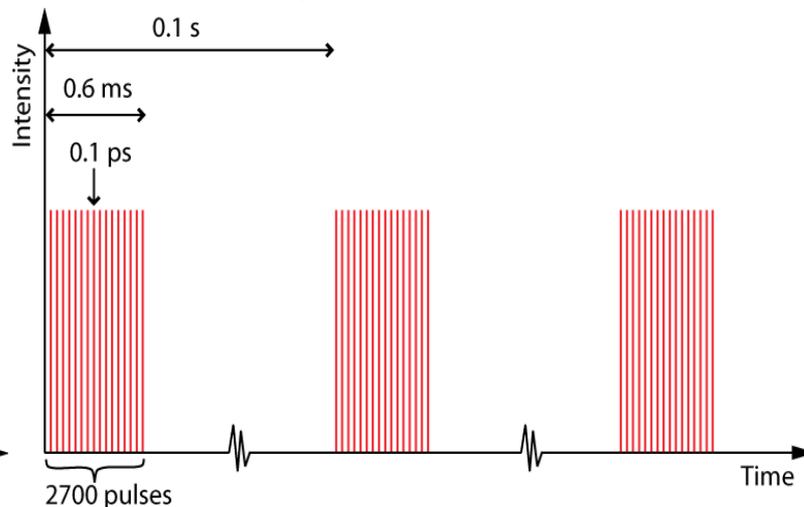
**Single-pulse:
~200-300 mJ/cm²**

LCLS



- 240 mW average power

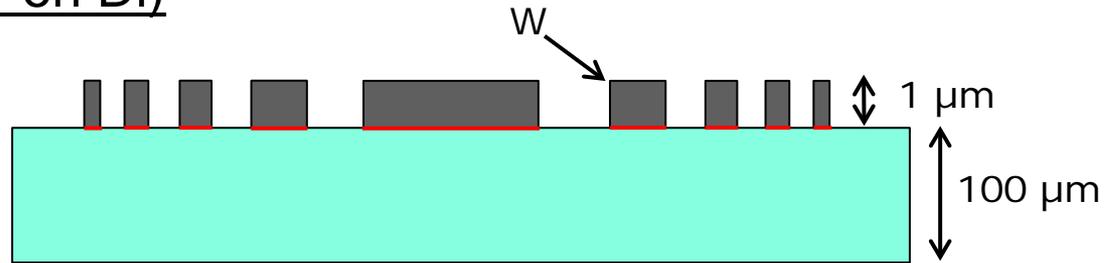
European XFEL



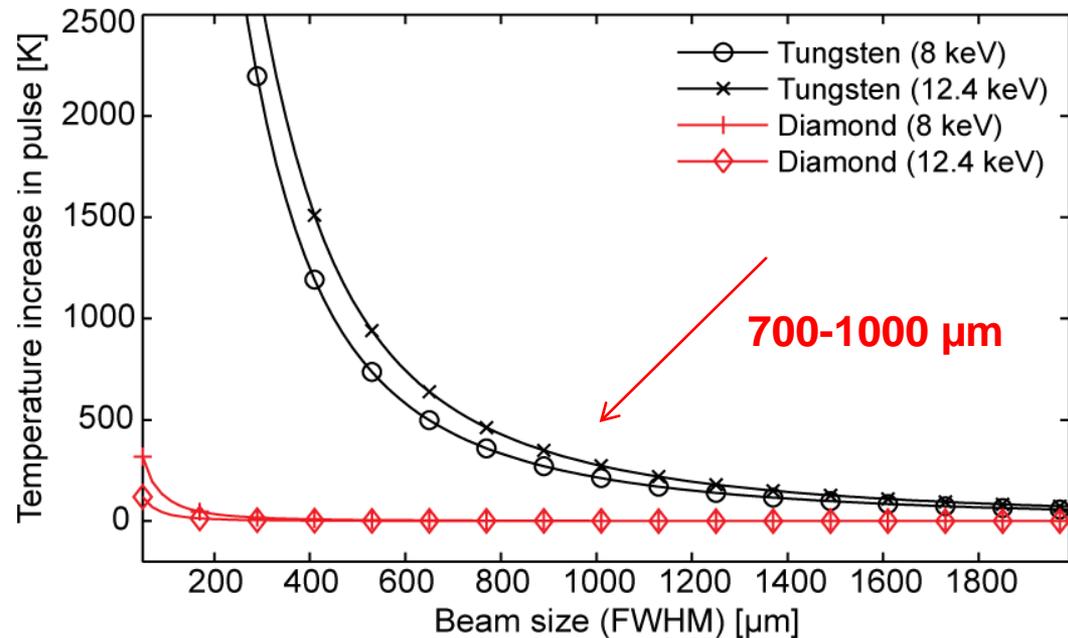
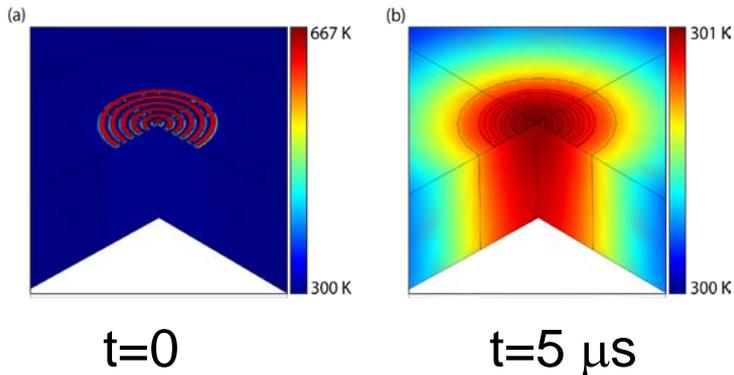
- 54 W average power
- 9000 W in pulse train

Hard x-ray metal zone plates: Thermal-Load Simulations

Tungsten on diamond (W on Di)



Single-pulse simulation

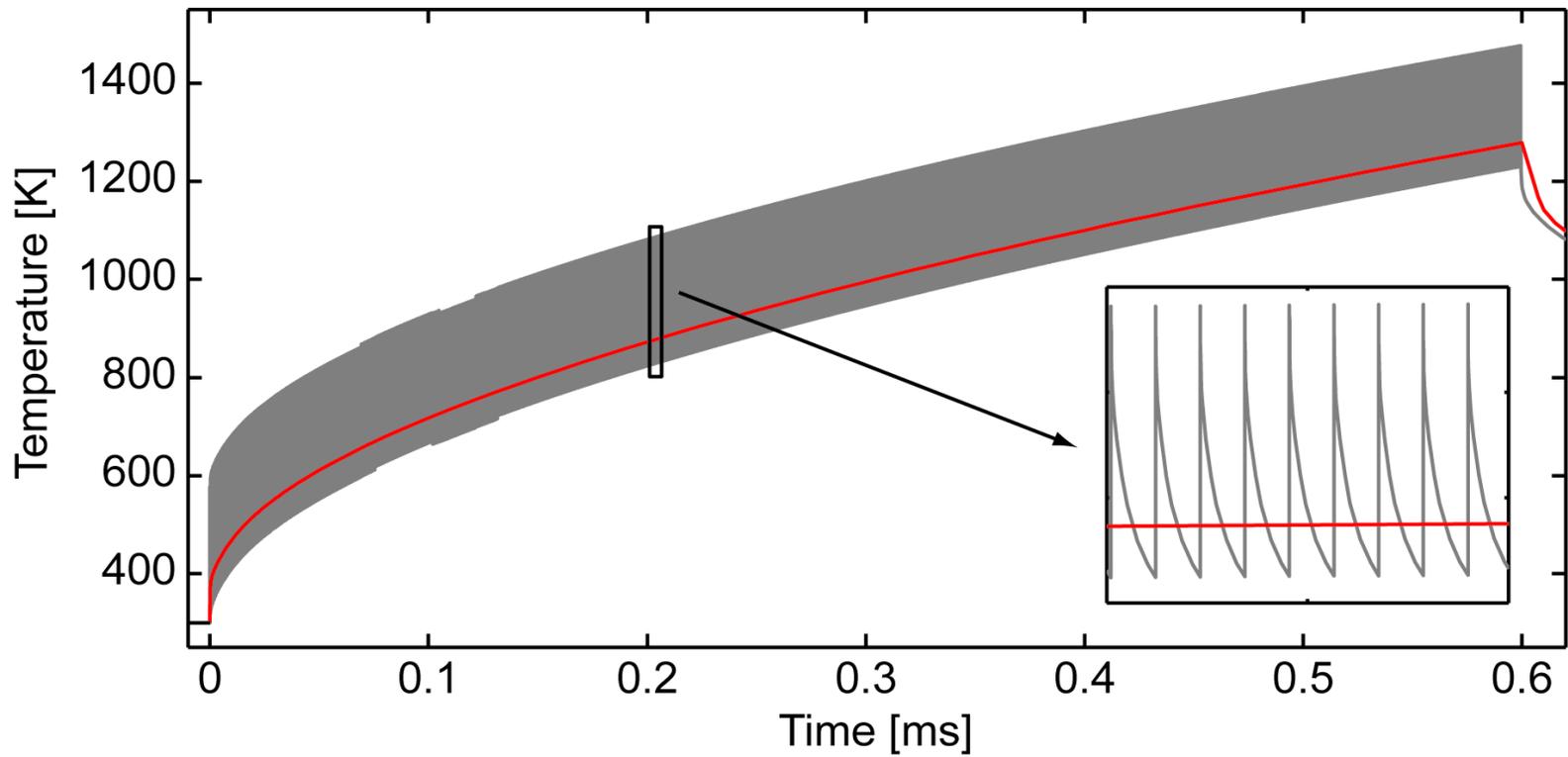


Nilsson et al, NIM A (2010), Nilsson et al, SPIE (2011)

W on Di zone plates: Thermal-Load Simulations for XFEL

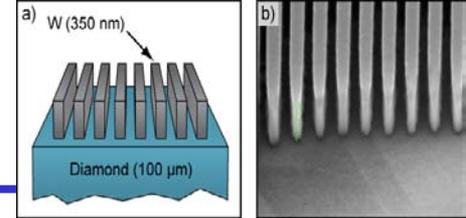
SASE1 @ XFEL:

Temperature in center of zone plate (Full pulse train)

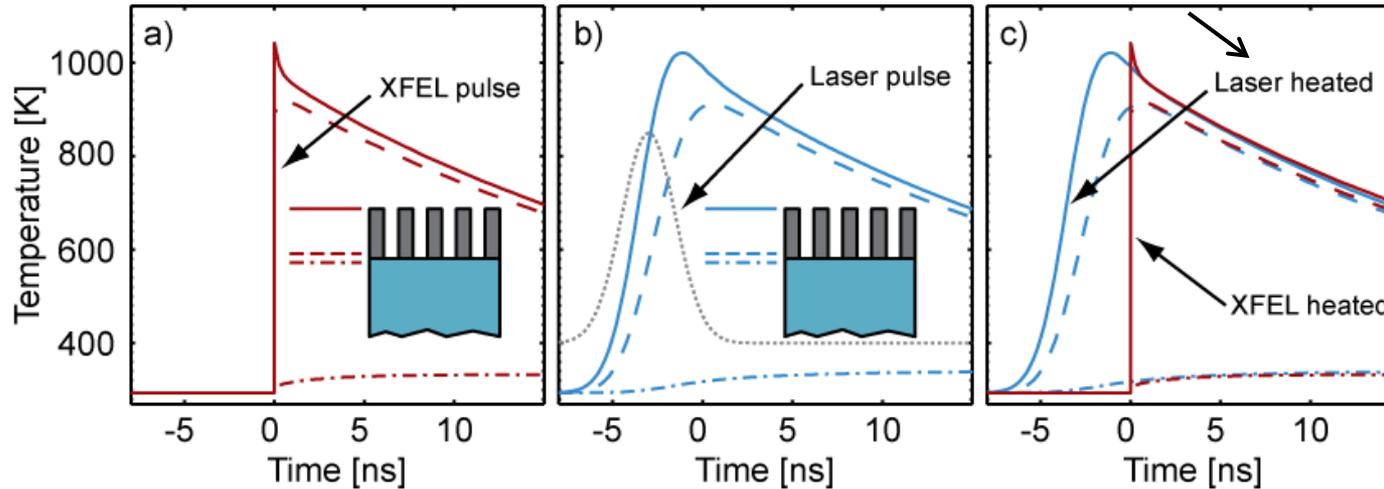


Nilsson et al, NIM A (2010),

Experiments vs Theory: YAG laser heating & first LCLS exp



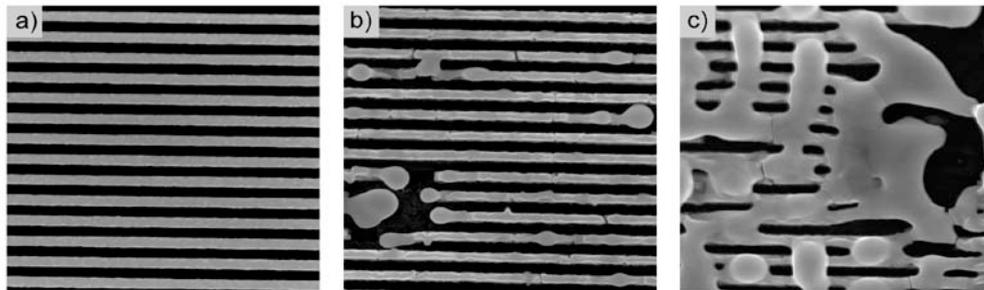
Single-pulse YAG-XFEL calibration



XFEL:
1 mJ/6 kV/350 mJ/cm²

Corresponds to
532 nm YAG:
3.5 ns/57 mJ/cm²

Low-rep-rate (20 Hz) YAG-laser operation:

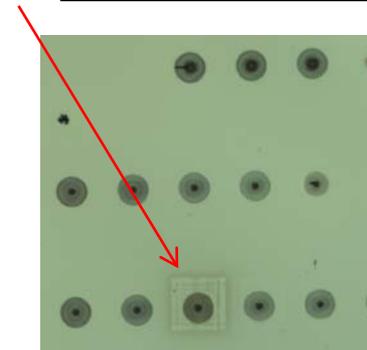


100 mJ/cm²
1.7 × 10⁶ pulses

180 mJ/cm²
7 × 10⁴ pulses

360 mJ/cm²
1.2 × 10³ pulses

First LCLS exp



6 kV, 120 Hz
1 mJ/500 μm

350 mJ/cm²
10⁵ pulses

LCLS exp: Thanks to Ch. David, PSI

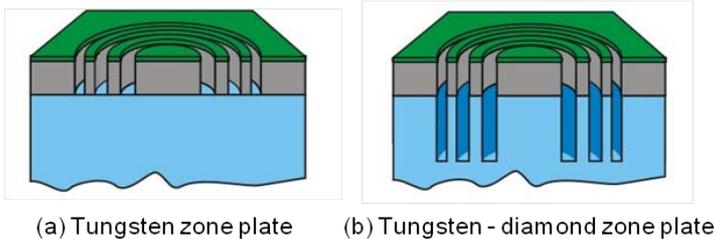
100 mJ/cm² YAG ↔ 590 mJ/cm² XFEL

Multi-material zone plates: Tungsten-Diamond (W-Di)

Why W-Di?

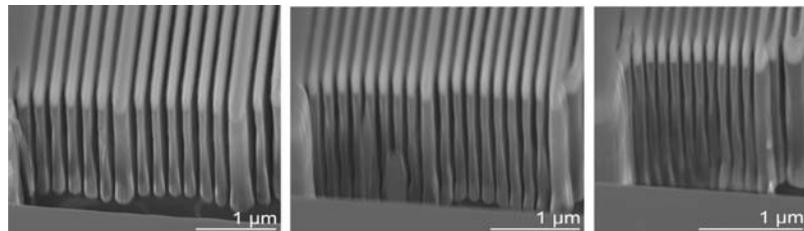
W \Rightarrow Small dr_n
High diffr efficiency
Di \Rightarrow High thermal conduct
Contributes to effic.

W-Di process



SF_6/O_2

O_2



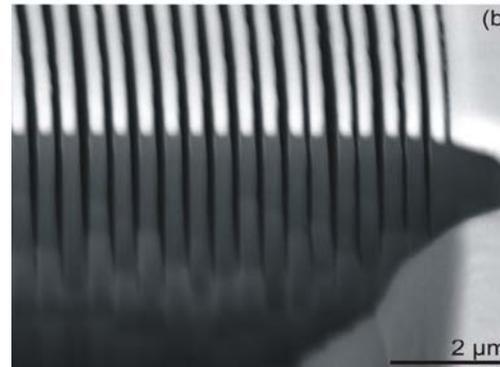
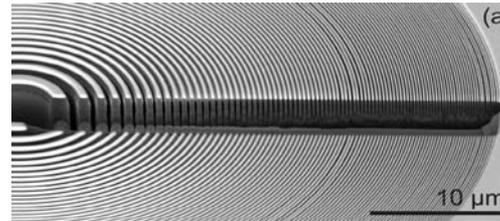
100

80

60

L/S (nm)

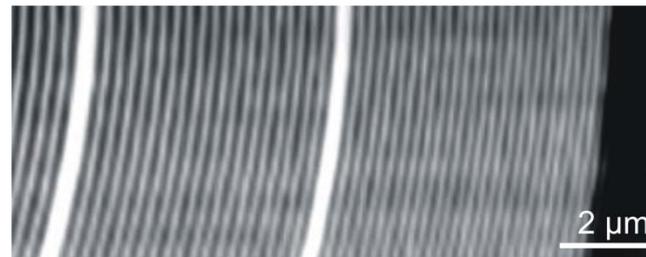
Results



W-Di zone plate
 ~ 200 nm W + ~ 2 μ m Di
 dr_n : 100 nm
Diam: 75 μ m

Effic @ ESRF
 $dr_n=100$ nm: 14%
 $dr_n=50$ nm: 7%

Imaging



100 nm W-Di zp
images
100 nm L/S (Au)
@ ESRF

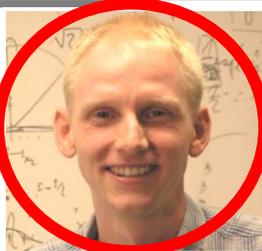
Uhlén et al, JVST (2011)

Summary & Future

- Soft X-Ray Diffractive Optics:
 - Improved efficiency with Ni-Ge multimaterial zone plates
 - Approaching 10 nm zone plates
 - Application: Laboratory x-ray microscopy
 - Approaches synchrotron quality
 - Resolution: <25 nm features
 - Contrast: improved via phase optics and system optimisation
 - Cryo 3D imaging
 - Next:
 - Increase efficiency
 - Shorter exp times w/ new laser; improved optics and system design
 - Applications: soils, colloids, cells, carbon content
- Hard X-Ray Diffractive Optics:
 - W on Di
 - Thermal properties appear OK for both LCLS and XFEL
 - Fabrication approaches 1:10 aspect ratio
 - W-Di increases efficiency
 - Next
 - Wavefront control
 - Prove small (<50 nm?) focus at LCLS
 - Increase efficiency.
 - NanoMAX BL @ MAXIV (U. Vogt et al)

Biomedical & X-Ray Physics group

Thanks!



E. H.



T. Z.

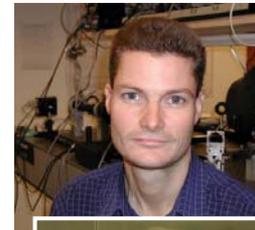
Soft x-rays:

Sources, optics, and microscopy

Hard x-rays:

Sources, optics & imaging

Ultrasonics & μ -fluidics:
Bio-analytics and cell biol.



Optics:

Peripheral vision



Teaching & technical